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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Applicants : Chandra V. Mouli and Ceredig Roberts  
Serial No. : 09/648,044  
Filed : August 25, 2000  
Confrm. No. : 6800  
Title : METHOD AND DEVICE TO REDUCE GATE-INDUCED DRAIN  
LEAKAGE (GIDL) CURRENT IN THIN GATE OXIDE MOSFETs  
Docket No. : MIO 0054 PA  
Examiner : O. Nadav  
Art Unit : 2811

**MAIL STOP AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**EFS WEB ELECTRONIC SUBMISSION**

**January 16, 2007**

**/William A. Jividen/  
Reg. No. 42,695**

Sir:

**AMENDMENT**

This paper is being filed in response to the Office Action mailed October 20, 2006.  
Reconsideration is respectfully requested in light of the amendments and remarks below.